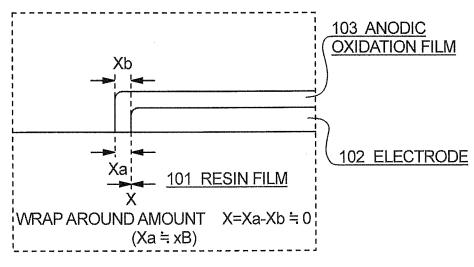
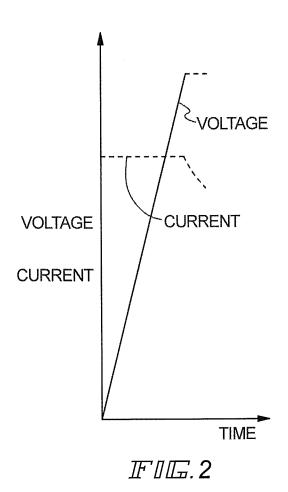
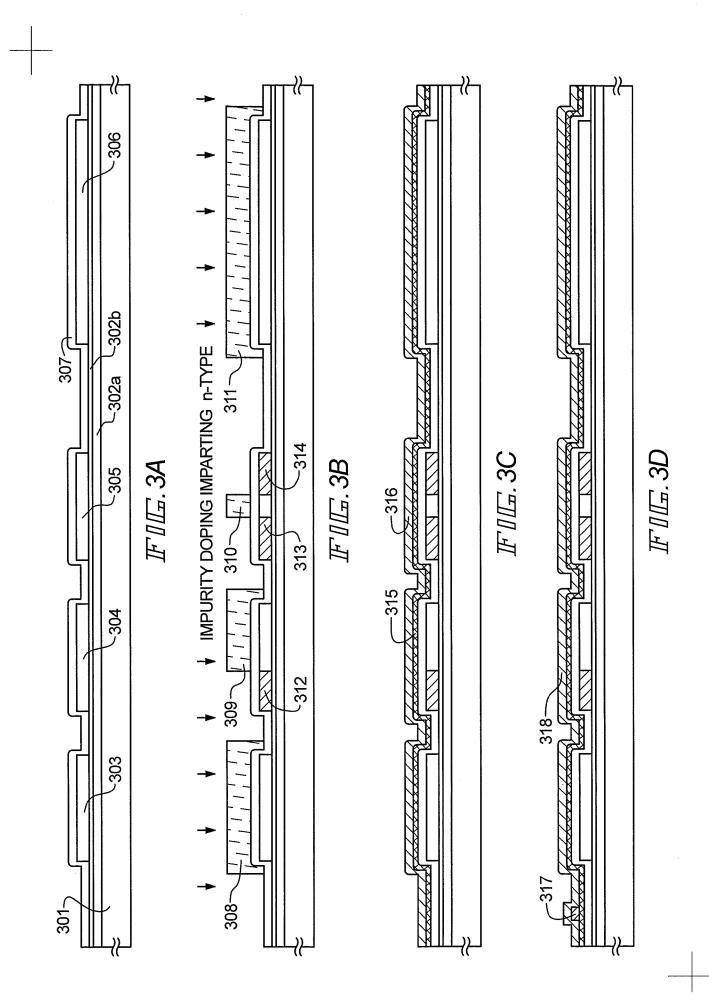


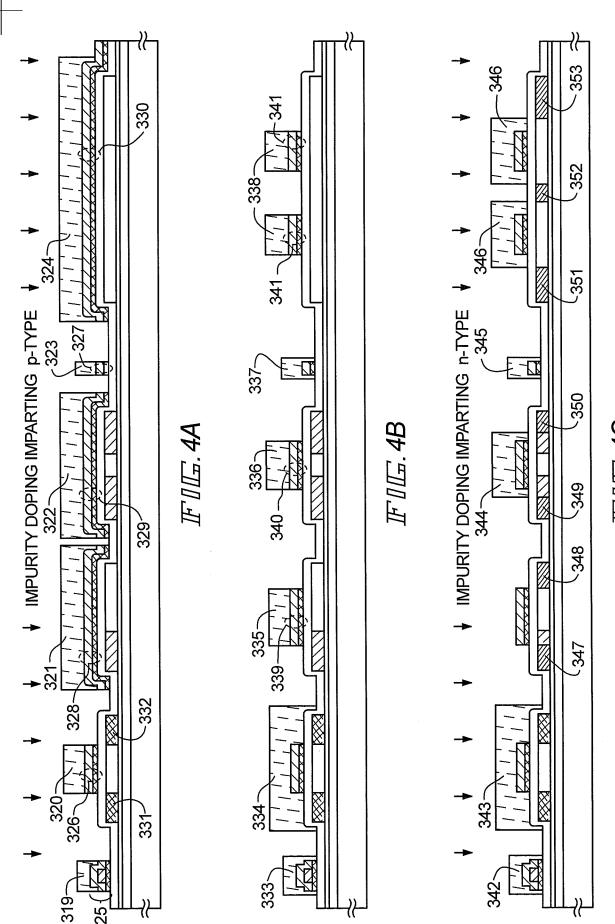
FIG. 1A
SEM PHOTOGRAPH (CROSS SECTION)



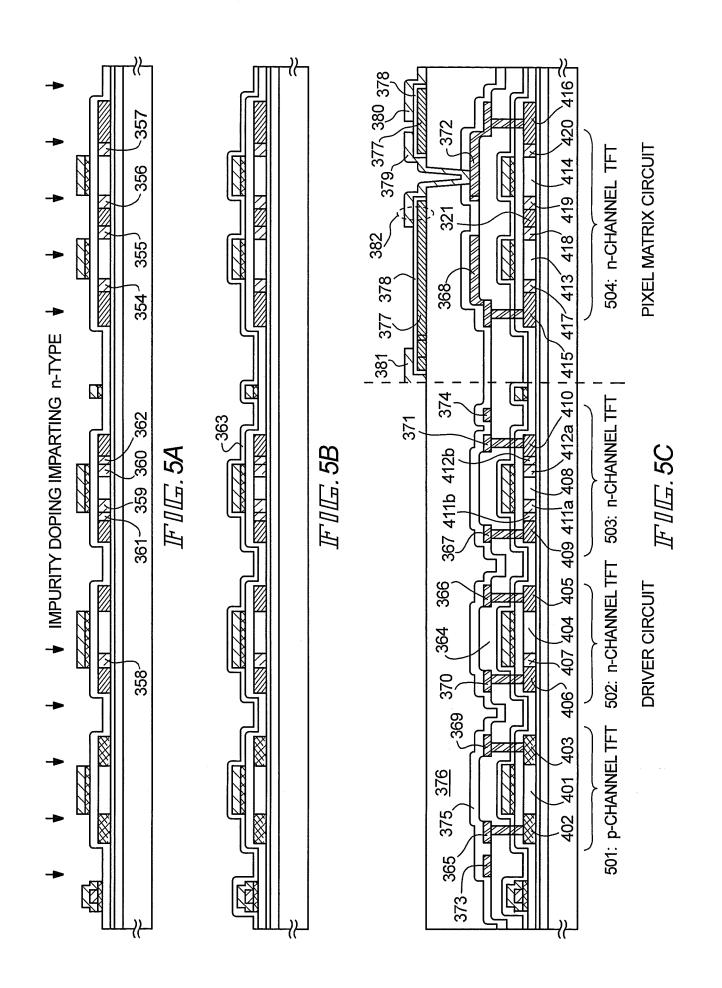
IF III. 1B
SCHEMATIC DIAGRAM OF ENLARGED ELECTRODE EDGE PORTION

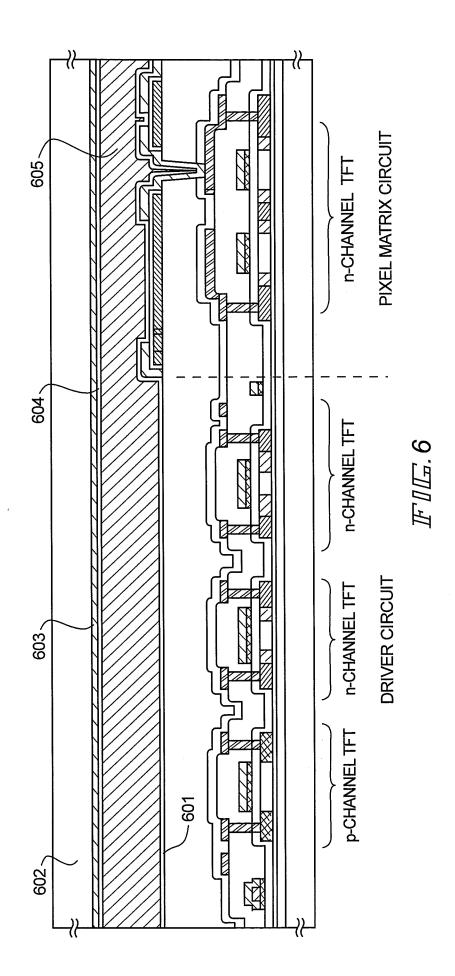


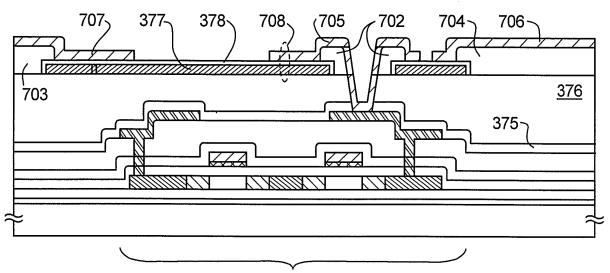




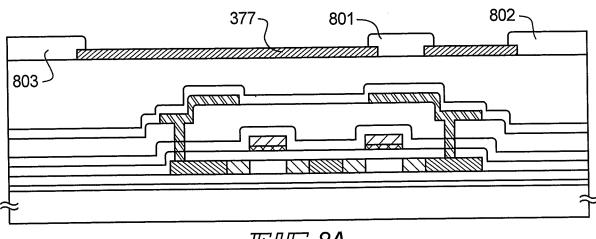
**正**[[压. 4C



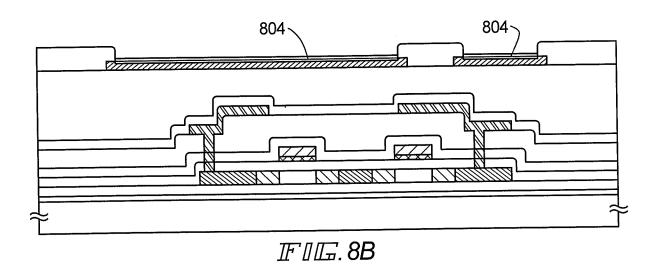


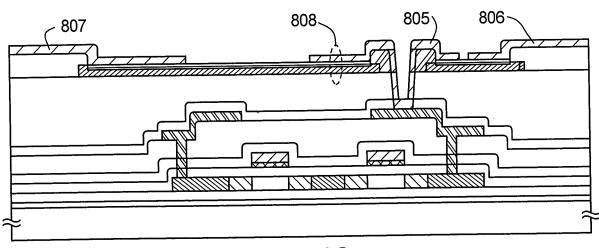


701: n-CHANNEL TFT

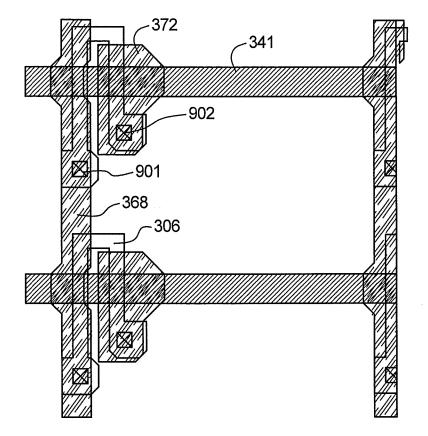


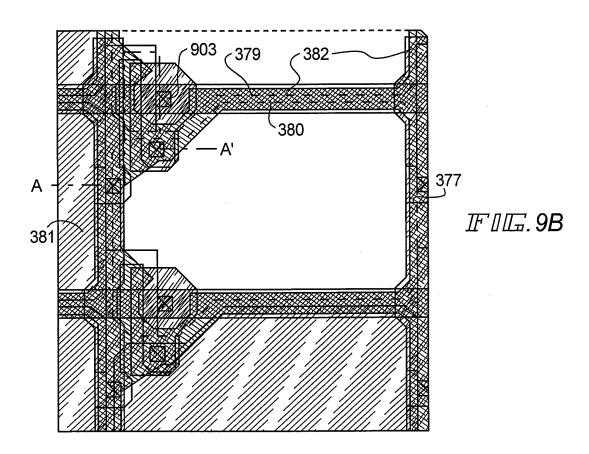
**FI匠.8A** 

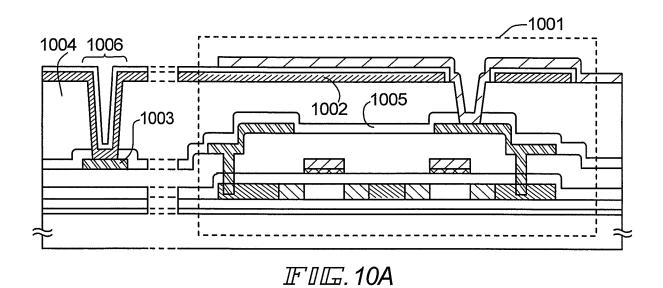


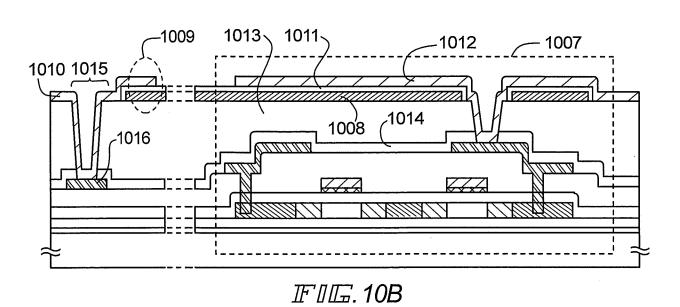


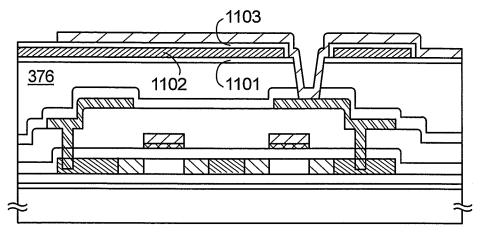
**F**I压.8C



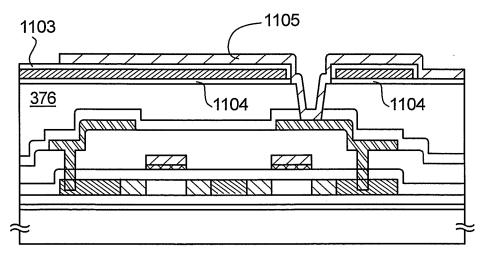




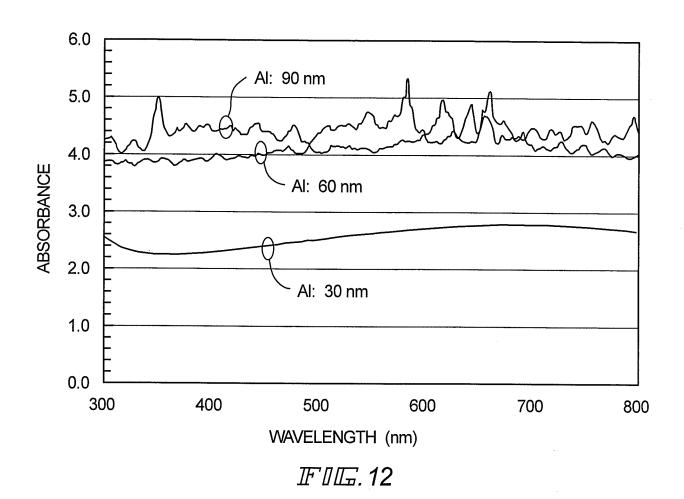


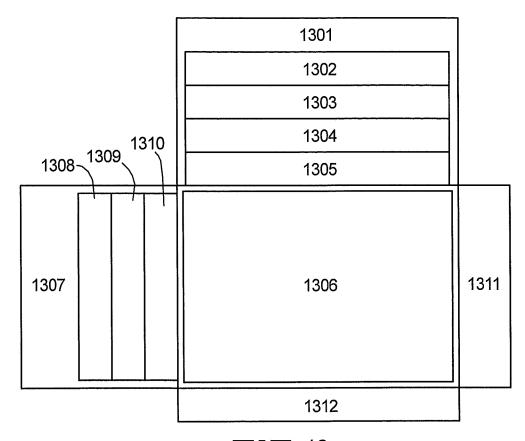


**『』『』『』. 11A** 

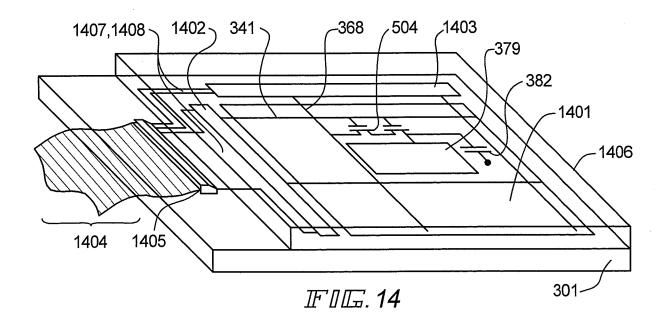


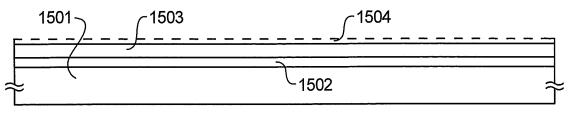
**F**[[压.11B



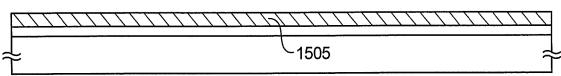


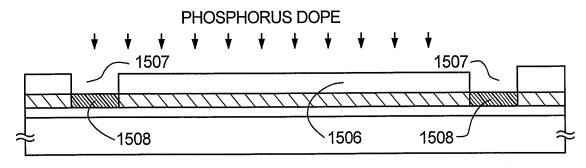
**F**[[压. 13

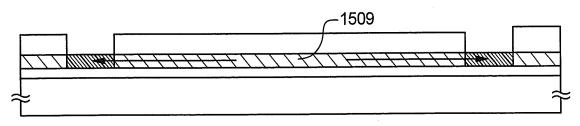


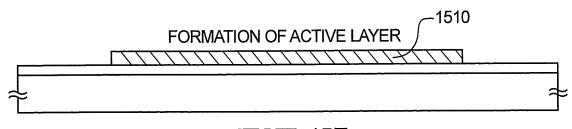


## **CRYSTALLIZATION**

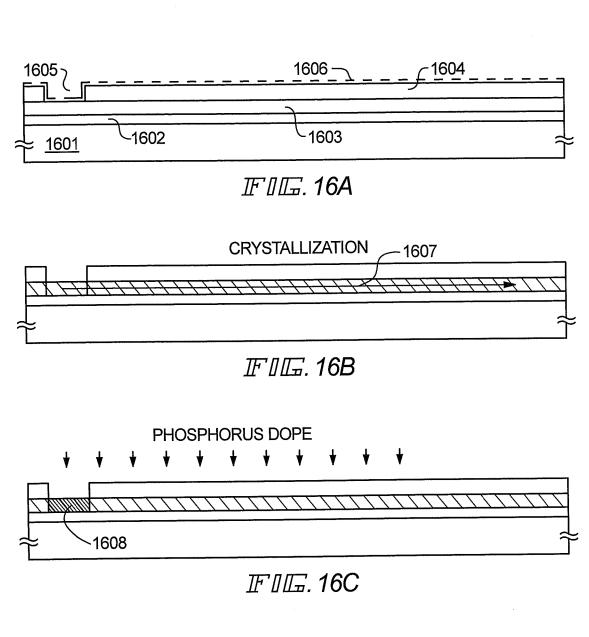


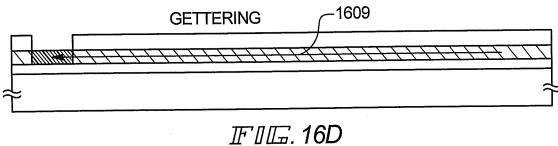


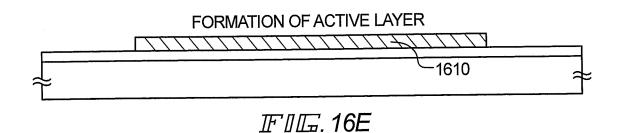


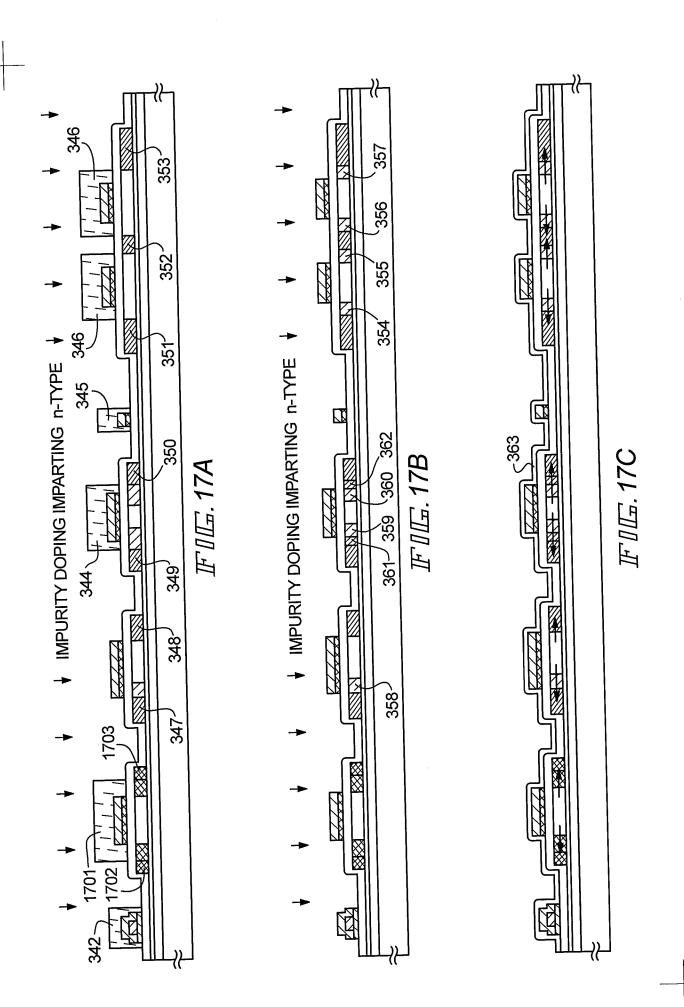


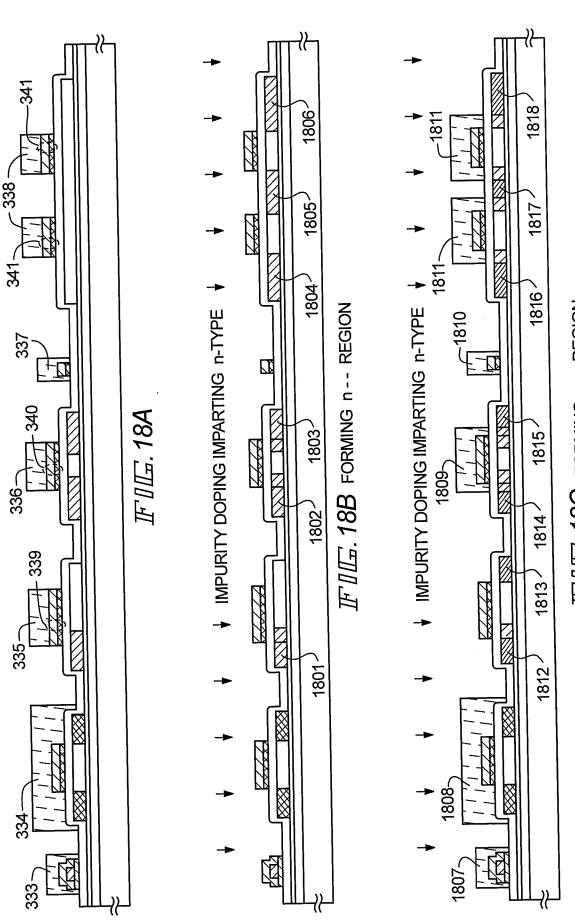
**F**II压. 15E



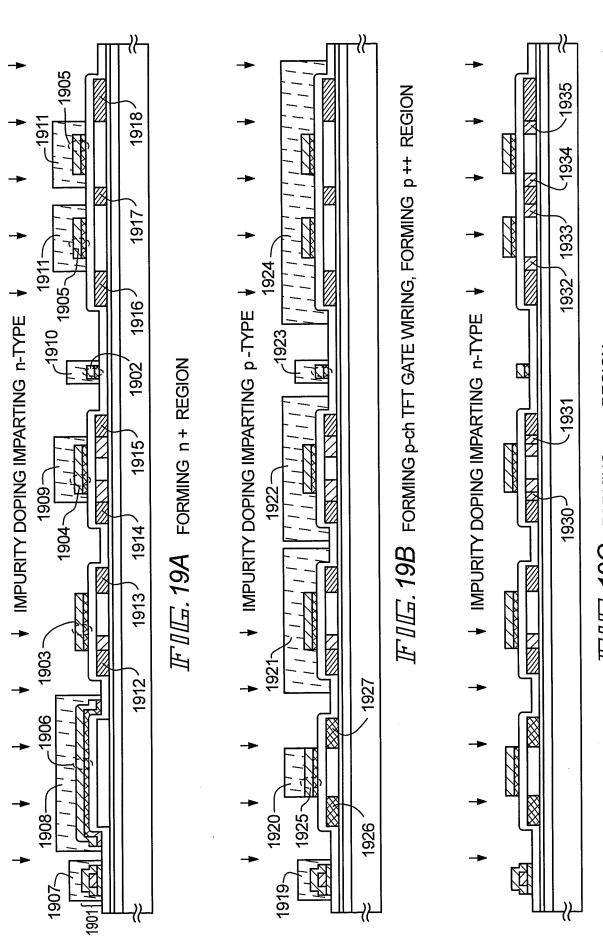




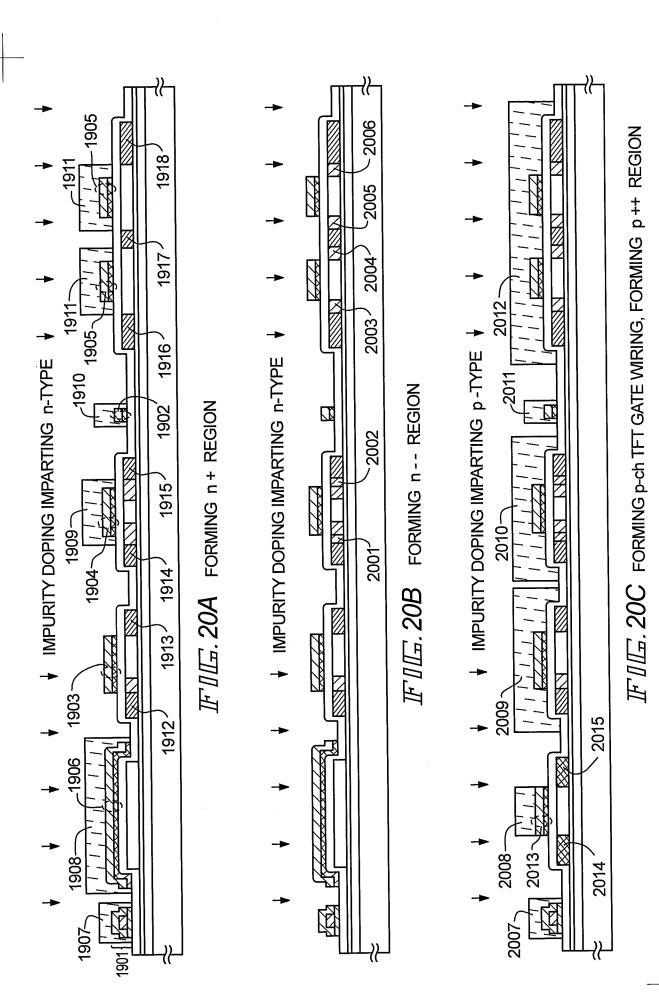


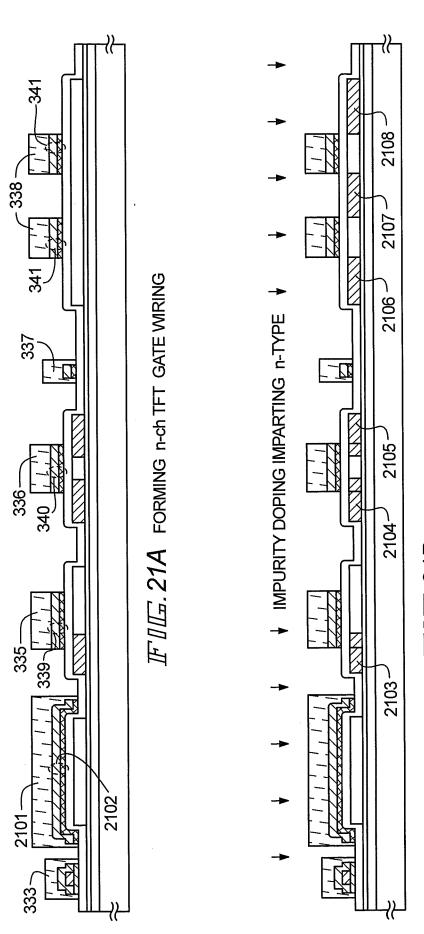


 $\mathbb{F}II\mathbb{Z}$ , 18C forming n + region

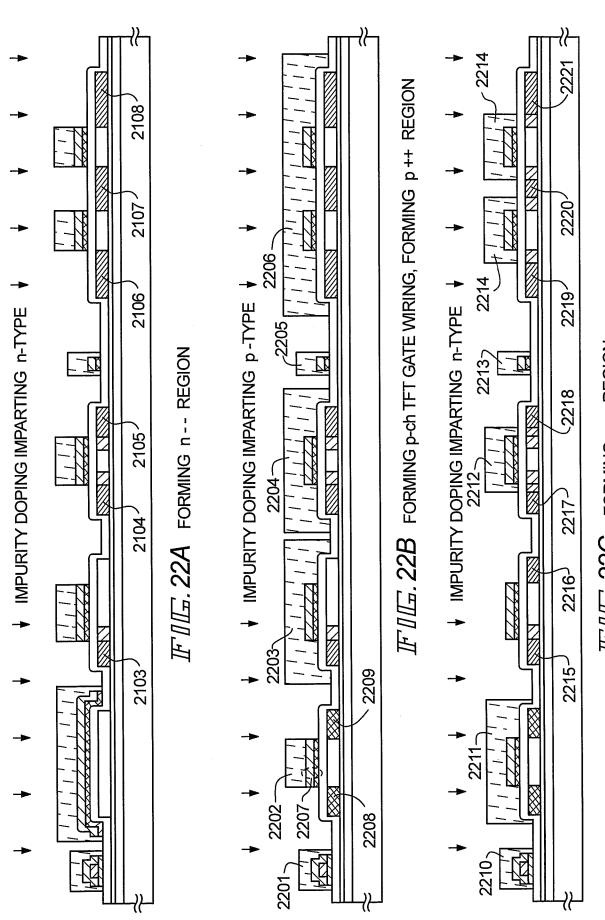


 $\mathbb{F}III_{\overline{n}}$ , 19C FORMING n-- REGION

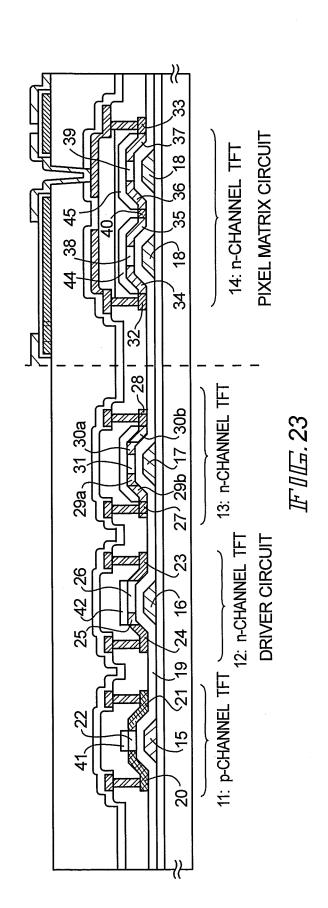


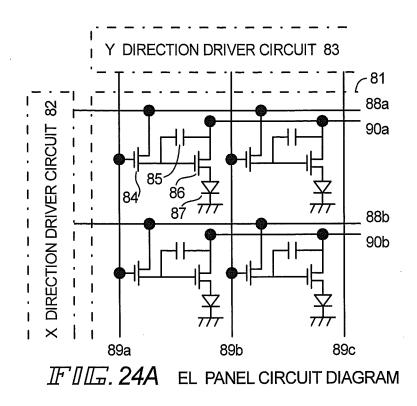


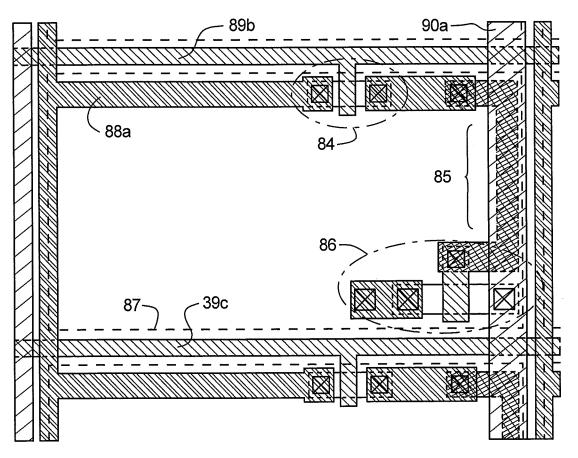
 $\mathbb{H}^{II}$   $\mathbb{H}_{2}$  . 21B FORMING n-- REGION



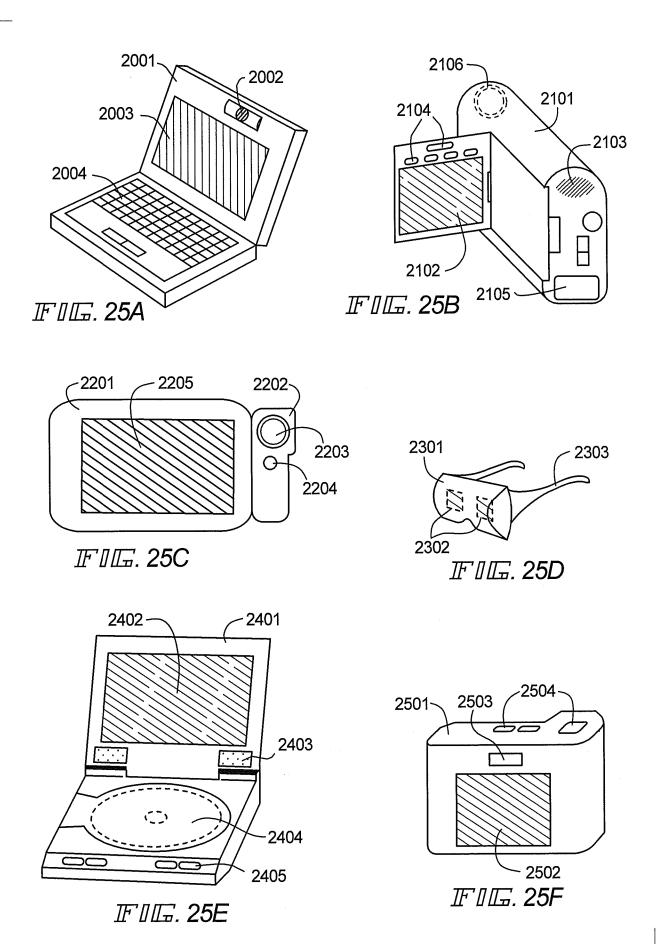
IFIII 22C FORMING n + REGION







IF III. 24B TOP VIEW OF EL PANEL PIXEL SECTION



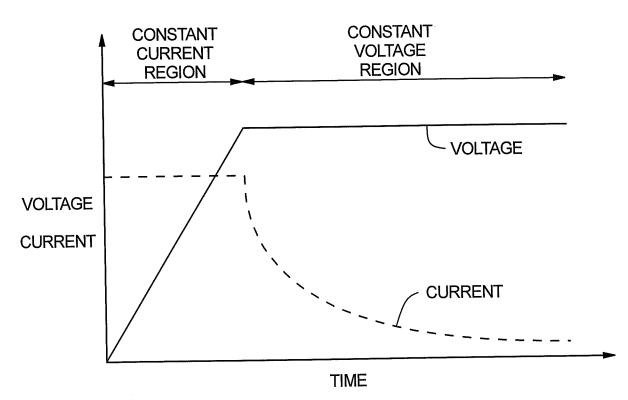
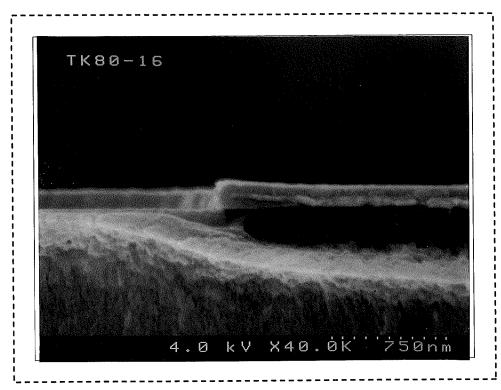


DIAGRAM SHOWING THE RELATIONSHIP BETWEEN VOLTAGE AND ELECTRIC CURRENT BETWEEN THE ELECTRODES IN A CONVENTIONAL ANODIC OXIDATION PROCESS

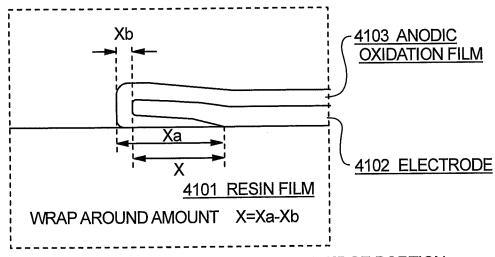
匠匠.26 PRIOR ART



SEM PHOTOGRAPH (CROSS SECTION)

IF III. 27A

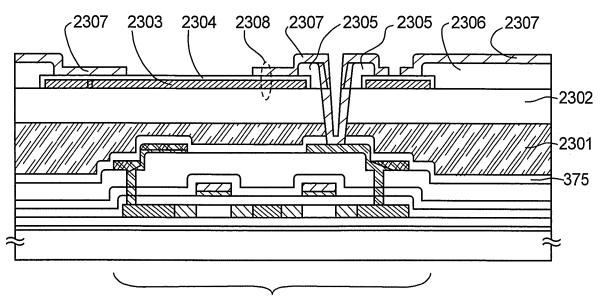
PRIOR ART



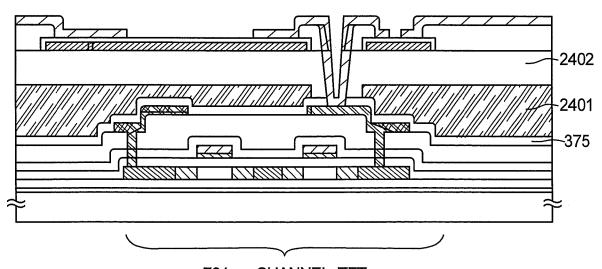
SCHEMATIC DIAGRAM OF ENLARGED ELECTRODE EDGE PORTION

IF III. 27B

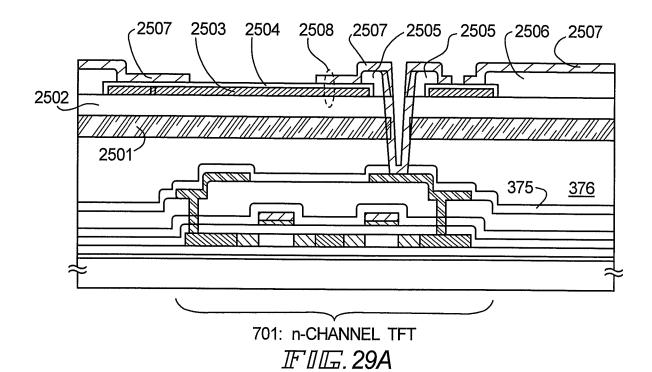
PRIOR ART

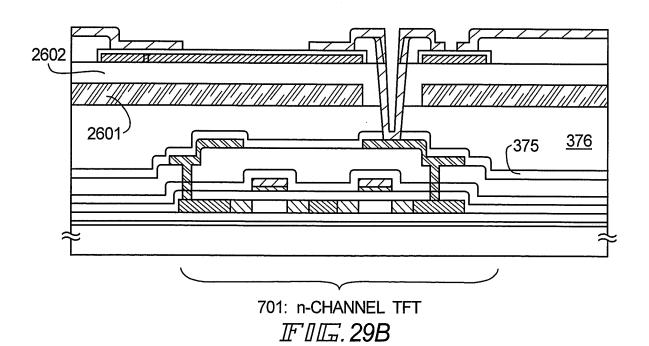


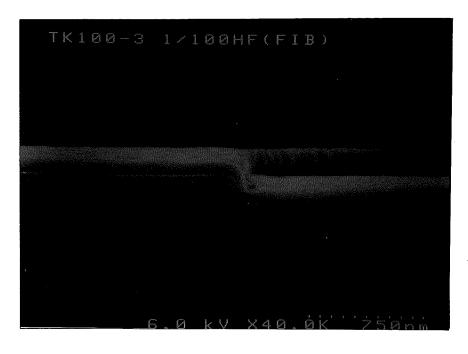
701: n-CHANNEL TFT



701: n-CHANNEL TFT

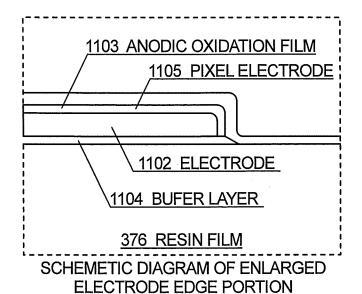






SEM PHOTOGRAPH (CROSS SECTION)

IF III. 30A



**』F』**[[].30B

